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(54) **Cathode-ray tube**

Kathodenstrahlröhre

Tube à rayons cathodiques

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Description

The invention relates to a cathode ray tube device comprising a cathode ray tube comprising in an evacuated envelope means to generate at least one electron beam behind which means, viewed in the direction of propagation of the electron beam, are provided successively a control electrode, an accelerating pre-focusing lens comprising a first and second lens electrode, each of said electrodes having an aperture for passing the at least one electron beam, and a main focusing lens, the device further comprising means to supply electric voltages to the electrodes, the cathode ray tube further comprising a phosphor screen on the inside of the evacuated envelope.

Such devices are known and used for instance for displaying monochromatic or multicolour pictures, for example television pictures.

Within the framework of the invention it has been found that, for some display devices, for those in which electron beams with relatively small beam currents (smaller than 1 mA) are formed, the spot quality can be improved vis-a-vis the known devices. Devices in which beams with a relatively small beam current are formed are below also called "low-current cathode ray tubes". In such currently known display tubes, e.g. colour monitor tubes (CMT's), typically beams with a maximum beam current of approximately 400 mA are generated in operation. By limiting the beam current a small spot size can be attained. Small spot sizes enable a high definition picture to be made. Spot sizes, meaning the average size of the spot at the centre of the phosphor screen within which 95% of all electrons of the beam hit the screen, of less than approximately 0.75 mm are attainable with known devices. Increasing the beam current has an advantage because it increases the brightness of the spot. An increased brightness of the spot is advantageous because e.g. an increase of contrast of the displayed images can be obtained, or a darker glass can be used for the envelope, which improves the image quality. However, with the known devices design also the spot size is increased, which decreases the image quality. For known devices the beneficial effects of an increased beam current are negated by the negative effect of the increased spot size. It is an object of the present invention to achieve an improvement of the image quality.

A display device according to the invention is characterized in that the means to supply voltages to the electrodes comprise means to supply a voltage difference V_{G2} between the control electrode and the first lens electrode, V_{12} , being greater than 800 Volt, and in that V_{G2}/S_{12} is greater than 4 Kev/mm, S_{12} being the distance between the control electrode and the first electrode and in that in operation the beam current is limited to an upper limit of 1 mA.

The following effect occurs due to the electrical field between the control electrode and the first electrode. The outermost rays of an electron beam emitted by the means for generating an electron beam are more focused than the paraxial rays by the electrical fields between the control electrode and the first lens electrode. A cross-over is thereby formed. The invention is a.o. based on the insight that for beam currents of the order of 0.5 to 1 mA the crossover occurs at a potential approximately around 800 V, and that the crossover location in space is a.o. dependant on the voltage difference V_{G2} between the control electrode and the first lens electrode. The voltage difference between the control electrode and the first lens electrode in current designs of low-current cathode ray tubes is approximately 500 V, and the field strength E_{12} between the control electrode and the first electrode is approximately 2.5 keV/mm. Such a voltage difference between the control electrode and the first lens electrode combined with such a field strength results in a crossover location approximately at a position underneath the first lens electrode. A voltage difference of more than 800 kV and a field strength between the control electrode and the first electrode of more than 4 kV/mm (as in the present invention) leads to a crossover at a position in between the control electrode and the first electrode. Under such conditions an improvement of the spot size is achieved, in particular for electron beams having a beam current of approximately 0.8 mA a spot size of less than 0.75 mm is obtained. Thus the beam current has been increased relative to the known devices, whereas the spot size has not been increased, resulting in an improved image quality. Preferably the field strength is larger than 6 kV/mm and smaller than 9 kV/mm.

A preferred embodiment is characterized in that the aperture size of the aperture in the control electrode is less than approximately 500 μm .

Within the framework of the invention it has been found that spot sizes increase with increasing aperture size in the control electrode. For apertures larger than 500 μm very high voltages and/or field strengths are necessary to achieve spot sizes of less than 0.75 mm.

A further preferred embodiment is characterized in that the aperture size of the aperture in the control electrode is larger than approximately 150 μm .

If the aperture size becomes less than 150 μm than either the distance between the control electrode and the means for generating the electron beam and/or the thickness of the control electrode have, in order to obtain a beam current of 0.8 mA, to be reduced to such small values that either there is a great risk of incidental electrical contact between the control electrode and the means for generating the electron beams or the mechanical strength of the control electrode is inferior.

With aperture size (d) is meant the size of the aperture, i.e. the square root of the area (A) of the aperture divided by $\pi/4$. For a circular aperture the aperture

$$\sqrt{(4A/\pi)}$$

size equals the diameter.

5 These and other aspects of the invention will be apparent from and elucidated with references to the embodiments described hereinafter.

Figure 1 is a horizontal longitudinal sectional view through a cathode-ray tube for use in a display device according to the invention.

Figure 2 is a longitudinal sectional view through an electron gun as used in the display device shown in figure 1.

10 Figure 3 shows a close-up detail of the electron gun shown in figure 2.

Figure 4 shows in a graphical form the spot size as a function of voltage.

Figure 5 shows in a graphical the spot size as a function of field strength.

The figures are schematic, simplified and not drawn to scale.

Figure 1 is a horizontal longitudinal sectional view of a cathode ray tube for a device according to the invention.

15 In this example the cathode ray tube is a colour cathode ray tube for use in a device for displaying colour pictures. Provided in the neck of a glass envelope 1 which comprises a display window 2, a cone 3 and said neck 4 is an electron gun system 5 which generates three electron beams 6, 7 and 8 which, in this example, are situated with their axes in one plane (for example the plane of drawing). The axis of the central electron beam 7 approximately coincides, when undeflected, with the tube axis. The display window 2 comprises on its inside surface 9 a display screen 10 which
20 display screen comprises, for example, a great number of triplet phosphor lines. Each triplet comprises a line consisting of a blue-luminescing phosphor, a line consisting of a red-luminescing phosphor, and a line consisting of a green-luminescing phosphor. The phosphor lines are, for example, substantially perpendicular to the plane of drawing. Positioned in front of the display screen 10 is a shadow mask 11 in which a large number of apertures 12 is provided through which the electron beams 6, 7 and 8 pass which each impinge only upon phosphor lines of one colour. The
25 three electron beams situated in one plane are deflected by the system of deflection coils 13. The invention is not restricted to the type of device shown, it may for instance be used in a device having a mono-chromatic cathode ray tube or a camera tube. The device further comprises means for supplying electric voltages to the electrodes. In figure 1 these means are schematically indicated by means 14.

Figure 2 is a longitudinal sectional view through an electron gun 21 as used in the exemplary display device shown in figure 1.

30 The electron gun 21 comprises a means for generating at least one electron beam. In this example it comprises three cathodes 22, 23 and 24 for generating three electron beams 6, 7 and 8. The electron gun further comprises a control electrode 25 which in this example is a joint electrode for the three electron beams. It further comprises a first lens electrode 26 and a second lens electrode 27. The first and second electrode 26, 27 form a pre-focusing lens. The
35 electron gun further comprises an electrode 28. The electrodes 27 and 28 form a main lens. Each electrode has apertures for passing the electron beams. The control electrode 25 is customarily called the G_1 -electrode, the first lens electrode is customarily called the G_2 -electrode.

Figure 3 shows schematically a close-up detail of the electron gun shown in figure 2.

40 Shown are, in this example, the emitting surface of cathode 22, the electrodes 26 and 25 and the equipotential lines 30. The potential of the equipotential lines is indicated. The diameter of the aperture in electrode 25 is indicated. The size D of the aperture in control electrode in this example is approximately 250 μm . The size of the aperture is to be understood to mean the average size of the aperture defined by the square root of the area of the aperture divided by $\pi/4$. For a circular aperture the size of the aperture is equal to the diameter. However, the invention is not restricted to circular apertures. The aperture in control electrode 25 can be for instance oval or rectangular.

45 In figure 3 the trajectories of electrons 31 emitted by the emitting surface of cathode 22 are shown for a beam current of 0.8 mA. It is shown in figure 3 that the outermost electrons cross each other before paraxial electron, i.e. electrons that are emitted near the centre of the cathode, cross each other. A so-called cross-over point is formed approximately at point 29. This point lies slightly below the 800 Volt equipotential line. According to a preferred embodiment of the invention the potential difference between control electrode 25 and first lens electrode 26 is greater
50 than 800 V, in this example approximately 1200 Volt. The distance between the electrodes 25 and 26, in figure 3 indicated by s_{12} , is (given in mm) less than $1200 \text{ Volt}/4 \text{ kV} = 0.300 \text{ mm}$. In this example s_{12} is approximately 0.160 mm.

In the framework of the invention it has been found that the crossover occurs at a potential approximately around 800 V, and that the crossover location in space is a.o. dependant on the voltage difference between the control electrode and the first lens electrode. The voltage on the first lens electrode in known devices is typically approximately 500 Volt.

55 A voltage difference between the control electrode and the first lens electrode of this magnitude combined with a relatively low field strength (smaller than 4 kV/mm) results in a crossover location 29 approximately underneath the first electrode 26. A voltage difference of more than 800 kV and a field strength between the control electrode and the first electrode of more than 4kV leads to a crossover in between the control electrode and the first electrode (see e.g.

fig. 3). In the framework of the invention it has been found that under such conditions an improvement of the spotsize is achieved.

This is illustrated in table 1 below. In this table for different electron guns the diameter of the aperture in the control electrode 25 is given (in table 1 denoted by G1 diameter), as well as the voltage difference between the control electrode 25 and the first lens electrode 26 (V_{G2}), and the ratio of this voltage and the distance between the control electrode and the first lens electrode ($= E_{12} = V_{G2}/S_{12}$).

Table 1:

gun #	#1	#2	#3	#4
G1 diameter[mm]	.35	.25	.20	.15
E_{12} [kV/mm]	2.8	7.7	6.8	6.1
V_{G2} [V]	552	1239	1231	601
0.8 mA 5% spot[mm]	.90	.70	.68	.77

The last lines of table 1 gives the spotsize on the screen for an electron beam with a beam current of 0.8 mA. The denotation 5% spot means that within the given diameter 95% of all electrons in the electron beam hit the screen. Below this will, for simplicity, also be called "the spot size".

Table 1 shows that making V_{G2} to be above 800 V and E_{12} to be larger than 4 kV/mm reduces the spotsize.

Figure 4 shows the spotsize of a 0.8 mA electron beam for a fixed fieldstrength E_{12} of 7.7 keV/mm as a function of the voltage difference V_{G2} . Figure 5 shows, for a fixed voltage difference of V_{G2} of 1239 V, the spot size as a function of the field strength E_{12} . Crosses indicate that the diameter of the aperture in G1 is 250 μ m, open squares indicate that said diameter is 200 μ m, full squares that said diameter is 150 μ m.

Preferably the field strength E_{12} is larger than 6 keV/mm. Between 4 and 6 keV/mm the spot size decreases whereas above 6 keV/mm the decrease is less prominent. Preferably E_{12} is less than 9 keV/mm. For values higher than 9 keV/mm the decrease in spot size is small, however, the change that arcing between electrodes G1 and G2 occurs is relatively high. Arcing may damage the electrodes.

The spot size is to a small degree dependent on the diameter of the aperture in electrode G1. Preferably the aperture is smaller than 500 μ m.

Preferably the diameter is larger than 150 μ m. If the aperture size becomes less than 150 μ m than either the distance between the control electrode and the means for generating the electron beam and/or the thickness of the control electrode have, in order to obtain reasonable beam currents, to be reduced to such small values that either there is a great risk of incidental electrical contact between the control electrode and the means for generating the electron beams or the mechanical strength of the control electrode is inferior.

Claims

1. A cathode ray-tube device comprising a cathode ray tube comprising in an evacuated envelope (1) means (21) to generate at least one electron beam behind which means, viewed in the direction of propagation of the electron beam, are provided successively a control electrode (25), an accelerating pre-focusing lens comprising a first (26) and second (27) lens electrode, each of said electrodes having an aperture for passing the at least one electron beam, and a main focusing lens (27,28), the device further comprising means (14) to supply electric voltages to the electrodes, the cathode ray tube further comprising a phosphor screen (10) on the inside of the evacuated envelope, characterized in that the means (14) to supply voltages to the electrodes comprise means to supply a voltage difference V_{G2} between the control electrode (25) and the first lens electrode (26), V_{G2} being greater than 800 Volt, and in that V_{G2}/S_{12} is greater than 4 keV/mm, S_{12} being the distance between the control electrode (25) and the first electrode (26) and in that in operation the beam current of the electron beam is limited to an upper limit of approximately 1 mA.
2. Cathode-ray tube device as claimed in claim 1, characterized in that V_{G2}/S_{12} is greater than 6 keV/mm.
3. Cathode-ray tube device as claimed in claim 1 or 2, characterized in that V_{G2}/S_{12} is smaller than 9 keV/mm.
4. Cathode-ray tube device as claimed in claim 1, 2 or 3, characterized in that the aperture size of the control electrode (25) is smaller than 0.5 mm.

5. Cathode ray tube as claimed in claim 1, 2, 3 or 4, characterized in that the aperture size of the control electrode (25) is greater than 0.15 mm.

5 Patentansprüche

1. Elektronenstrahlröhrenanordnung mit einer Elektronenstrahlröhre, die in einer evakuierten Hülle (1) Mittel (21) aufweist zum Erzeugen wenigstens eines Elektronenstrahls, wobei hinter diesen Mitteln, gesehen in der Richtung der Fortpflanzung des Elektronenstrahls, hintereinander eine Steuerelektrode (25), eine beschleunigende Vorfokussierungslinse mit einer ersten (26) und einer zweiten (27) Linsenelektrode, wobei jede der genannten Elektroden eine Öffnung aufweist zum Hindurchlassen des wenigstens einen Elektronenstrahls, sowie eine Hauptfokussierungslinse (27, 28) vorgesehen sind, wobei die Anordnung weiterhin Mittel (14) aufweist zum Liefern elektrischer Spannungen zu den Elektroden, wobei die Elektronenstrahlröhre weiterhin auf der Innenseite der evakuierten Hülle einen Phosphorschirm (10) aufweist, dadurch gekennzeichnet, daß die Mittel (14) zum Liefern von Spannungen zu den Elektroden Mittel aufweisen zum Liefern einer Spannungsdifferenz V_{G2} zwischen der Steuerelektrode (25) und der ersten Linsenelektrode (26), wobei diese Differenz V_{G2} größer ist als 800 Volt, und daß V_{G2}/S_{12} größer ist als 4 Kev/mm, wobei S_{12} der Abstand zwischen der Steuerelektrode (25) und der ersten Elektrode (26) ist und daß im Betrieb der Strahlstrom auf eine obere Grenze von 1 mA begrenzt ist.
2. Elektronenstrahlröhrenanordnung nach Anspruch 1, dadurch gekennzeichnet, daß V_{G2}/S_{12} größer ist als 6 keV/mm.
3. Elektronenstrahlröhrenanordnung nach Anspruch 1 oder 2, dadurch gekennzeichnet, daß V_{G2}/S_{12} kleiner ist als 9 keV/mm.
4. Elektronenstrahlröhrenanordnung nach Anspruch 1, 2 oder 3, dadurch gekennzeichnet, daß die Öffnungsgröße der Steuerelektrode (25) kleiner ist als 0,5 mm.
5. Elektronenstrahlröhrenanordnung nach Anspruch 1, 2, 3 oder 4, dadurch gekennzeichnet, daß die Öffnungsgröße der Steuerelektrode (25) größer ist als 0,15 mm.

Revendications

1. Dispositif à tube à rayons cathodiques comprenant un tube à rayons cathodiques comportant, dans une enveloppe sous vide (1), un moyen (21) pour générer au moins un faisceau d'électrons, moyen derrière lequel vu dans le sens de propagation du faisceau d'électrons, sont prévus successivement une électrode de commande (25), une lentille préfocalisatrice d'accélération comprenant une première (26) et une deuxième (27) électrode de lentille, chacune desdites électrodes ayant une ouverture pour le passage d'au moins un faisceau d'électrons, et une lentille principale de focalisation (27, 28), le dispositif comprenant en outre des moyens (14) pour fournir des tensions électriques aux électrodes, le tube à rayons cathodiques comprenant en outre un écran phosphorescent (10) sur le côté interne de l'enveloppe sous vide, caractérisé en ce que les moyens d'alimentation (14) destinés à fournir des tensions aux électrodes, comprennent des moyens destinés à établir une différence de tension V_{G2} entre l'électrode de commande (25) et la première électrode de lentille (26), V_{G2} étant supérieure à 800 V, et en ce que V_{G2}/S_{12} est supérieur à 4 keV/mm, S_{12} étant la distance séparant l'électrode de commande (25) et la première électrode (26) et en ce que, en fonctionnement, le courant de faisceau du faisceau d'électrons est limité à une limite supérieure d'approximativement 1 mA.
2. Dispositif à tube à rayons cathodiques suivant la revendication 1, caractérisé en ce que V_{G2}/S_{12} est supérieur à 6 keV/mm.
3. Dispositif à tube à rayons cathodiques suivant la revendication 1 ou 2, caractérisé en ce que V_{G2}/S_{12} est inférieur à 9 keV/mm.
4. Dispositif à tube à rayons cathodiques suivant la revendication 1, 2 ou 3, caractérisé en ce que la taille de l'ouverture de l'électrode de commande (25) est inférieure à 0,5 mm.
5. Dispositif à tube à rayons cathodiques suivant la revendication 1, 2, 3 ou 4, caractérisé en ce que la taille de

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l'ouverture de l'électrode de commande (25) est supérieure à 0,15 mm.

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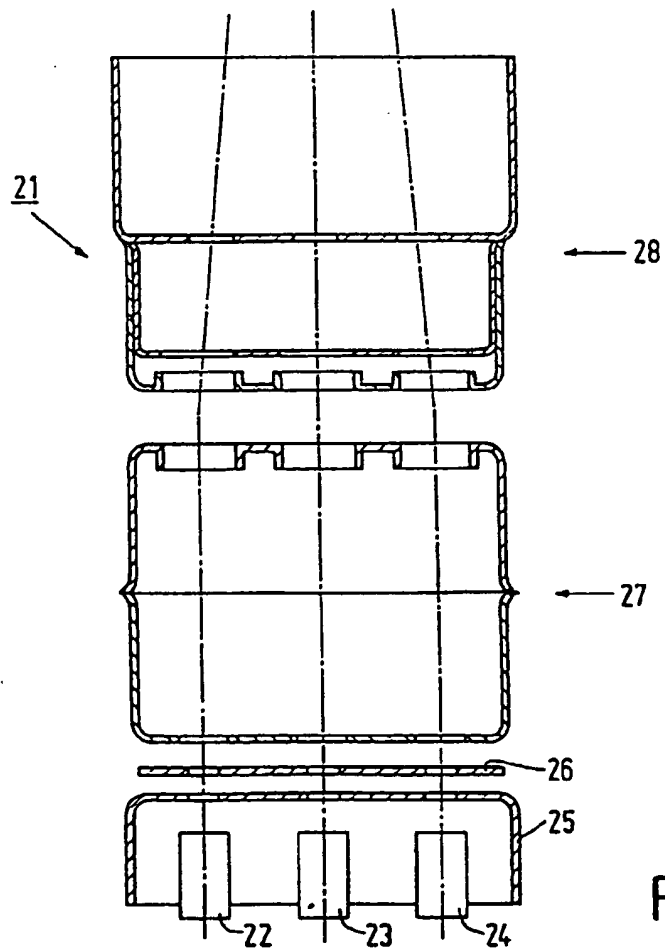
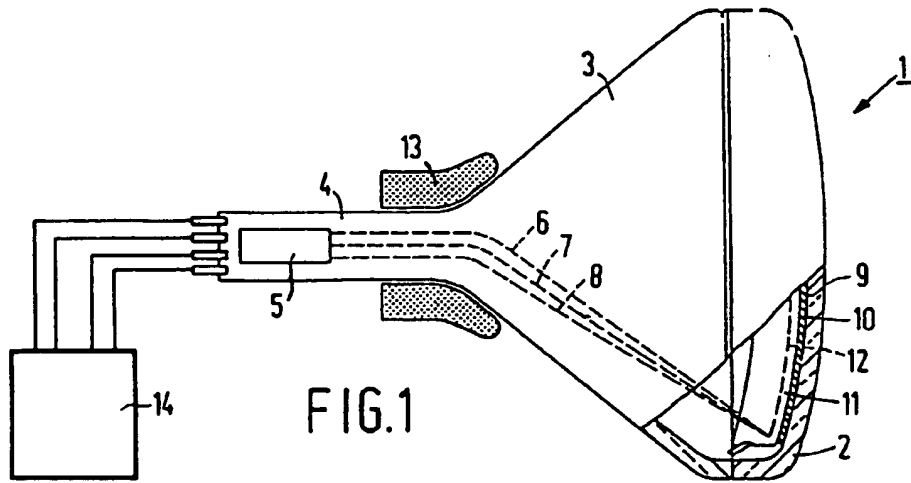
35

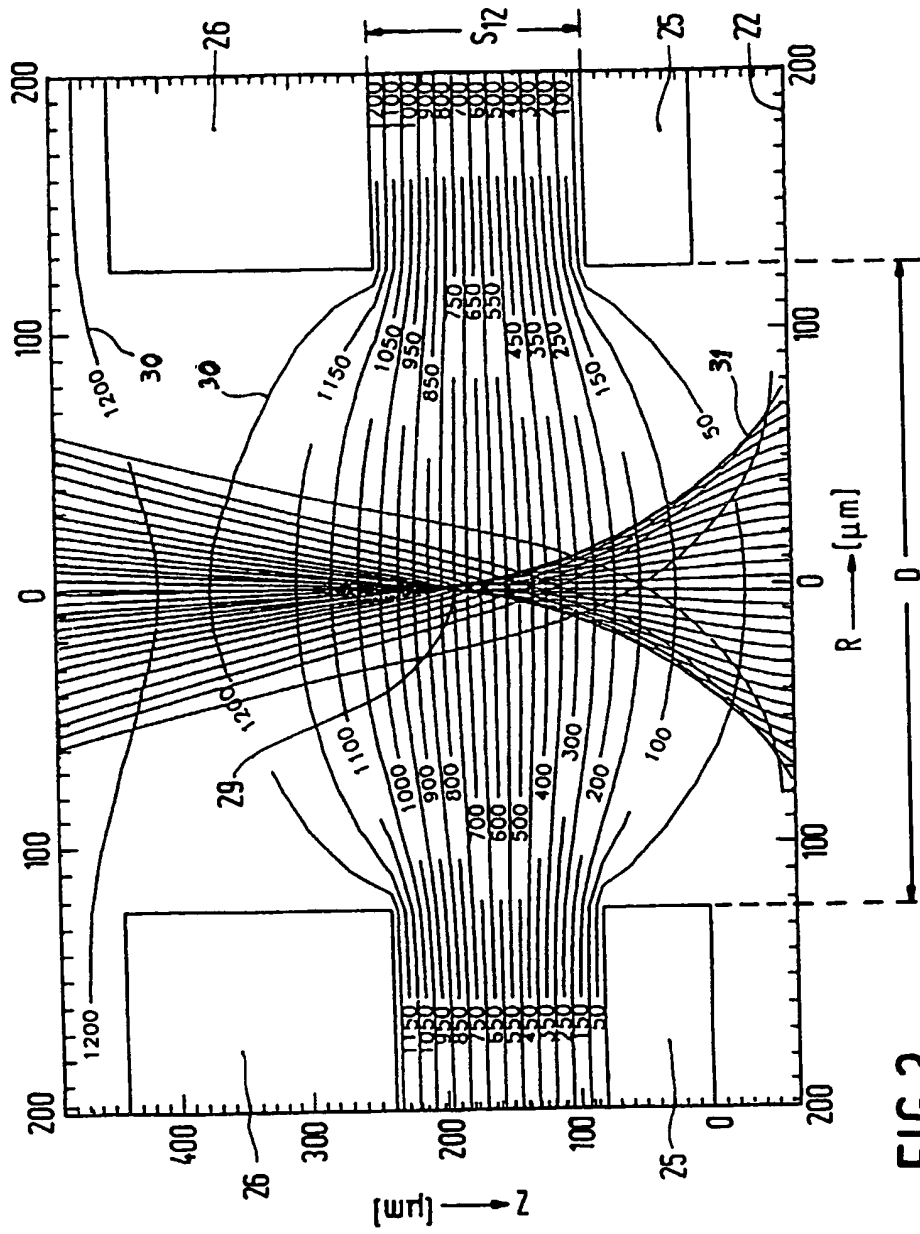
40

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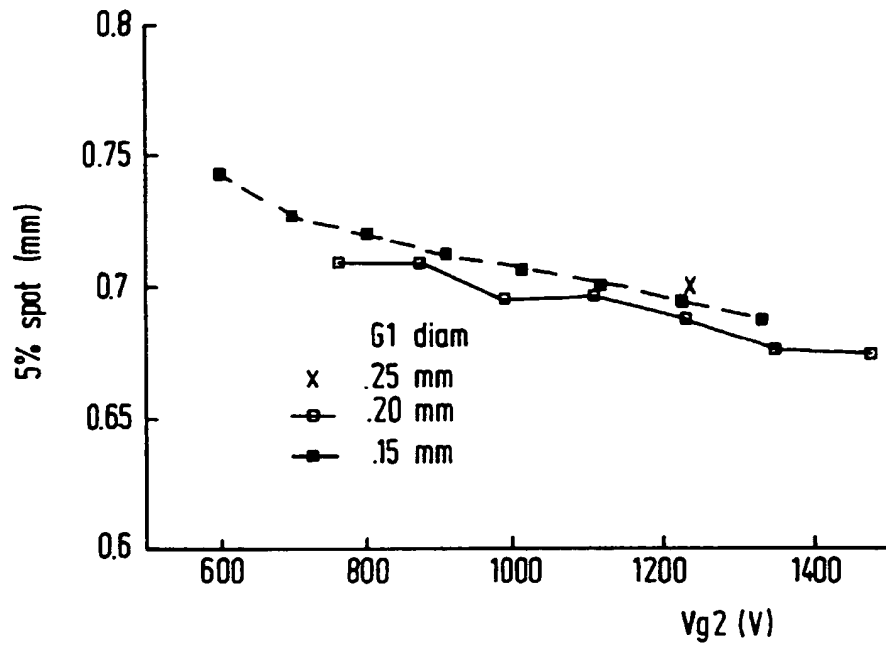


FIG.4

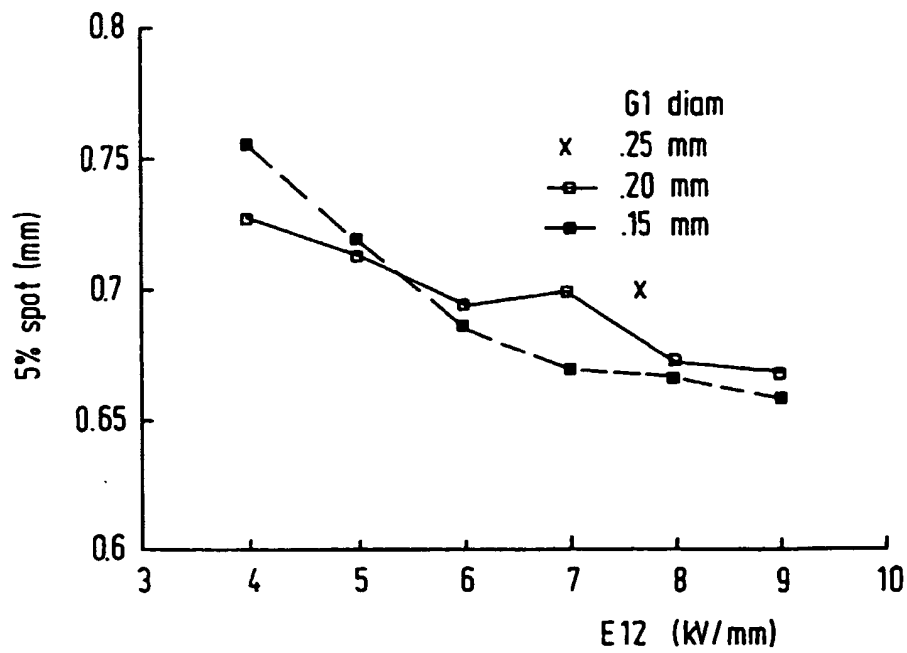


FIG.5